JS401-200 Spin Coater

200 mm Spin Coater

The JS401-200 benchtop Series of small substrate spincoaters is designed for versatility, ease of use and safety in a variety of manual and automated research and development processes. The spincoaters are ideal for processes such asthe coating and developing of silicon wafers, glasses, large photomasks, reticles.

- Easy to clean up the bowl
- Easy to use
- Repeatable performance
- Flexibility
- Programmability in an economical, benchtop system.

Specification

Programmable 20 steps, 20 recipes stored PLC and Touch panel operation Acuracy +- 1 RPM Max RPM: 4,500

Acceleration and decelleration settable by 0.1 sec.

Acceleration: 3,000RPM/sec. SUS304 body and bowl

for easy cleaning and chemical resistance

Drain port

Clear PC cover for bowl Max 200mm diameter plate

Standard dry vacuum pump: 100 liter/min, 0.5 ATM

Standard sample chuck

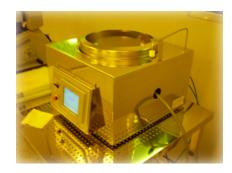
Dimension 500W x 500D x 375H mm

220VAC, 60Hz, 5 amp

Weight: 25 Kg









JAESUNG JS401 SPIN COATING SYSTEM